



PATENT  
YOR920040022 IBM-272

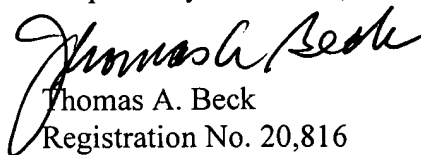
IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re Application of : Matthew Colburn, et al.  
Serial Number : 10/799,282  
Filing Date : March 13, 2004  
Examiner : To Be Determined  
Group Art Unit : To Be Determined  
For : Method for Fabricating Dual Damascene Structures  
Using Photo-Imprint Lithography, Methods for  
Fabricating Imprint Lithography Molds for Dual  
Damascene Structures, Materials for Imprintable  
Dielectrics and Equipment for Photo-Imprint  
Lithography Used in Dual Damascene Patterning.

TO: The Honorable Commissioner of Patents  
and Trademarks  
Washington, D.C. 20231

Applicants enclose herewith an original copy of the fully signed declaration in this case.  
The Commissioner is hereby authorized to charge Deposit Account 50-0510 the amount of  
\$130.00 to cover the cost of the declaration surcharge. A duplicate copy of this page is  
enclosed.

Respectfully Submitted,

  
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I hereby certify that this paper is being transmitted by First Class mail addressed to  
Commissioner of Patents & Trademarks, Post Office Box 1450, Alexandria, VA 22313-1450.

Signature:   
Name: Thomas A. Beck

Date: June 17, 2004